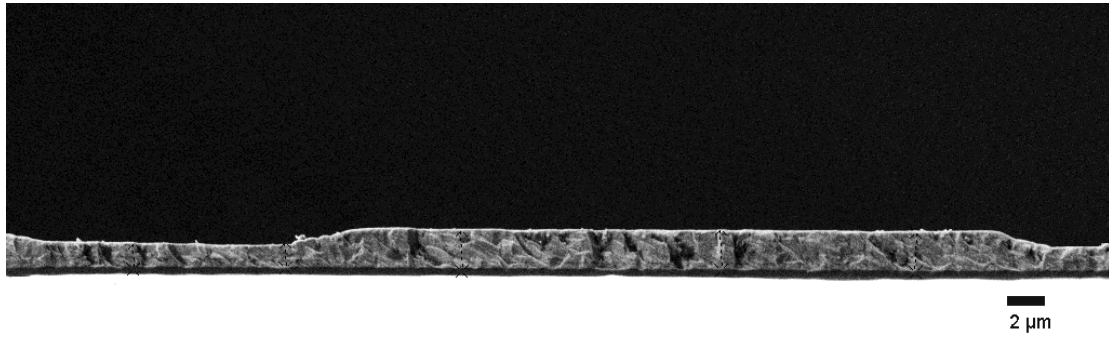
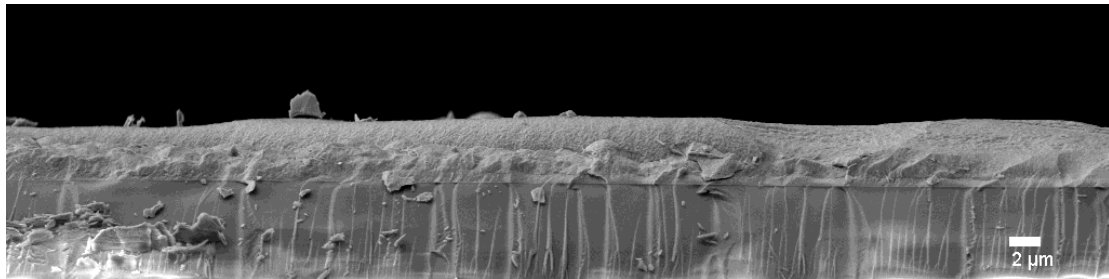


## Supporting Information

a)



b)



**Figure 1: Side on SEM images of the AACVD film grown at (a) 500 °C and (b) 550 °C. The thickness of the film grown at 500 °C (a) is between 1-2 μm while the thickness of the 550 °C (b) ranges between 3 to 4 μm.**